

LIST OF REFERENCES CITED BY APPLICANT

Atty Docket No.: 4100-98DIV
Serial No.: 09/041,416
Applicant: Alfons SCHUSTER et al.

Filing Date: Mar 12, 1998
Group Art: 2854

#8
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FOREIGN PATENT DOCUMENTS

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<i>ff</i>	AF	37 13 801	11/10/88	Germany	Alexander			
	AG							
	AH							
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OTHER REFERENCES (Including Author, Title, Date, Pertinent Pages, Etc.)

<i>ff</i>	AK		Article entitled "Neue Technologien zur filmlosen Herstellung von Druckformen" by Von Hansjörg W. Vollmann taken from Angew. Chem. 92, 95-106 (1980), pp 95-106
	AL		
	AM		

EXAMINER:

Stephen Feink

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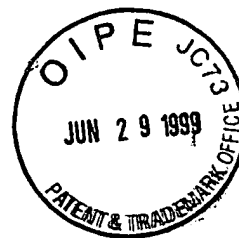
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<i>SP</i>	AF	2 154 012	01/23/96	Canada	<i>Nussel</i>	 	 	
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